Experimental Investigation of Carbon Nanotubes Counter Electrodes for Dye-Sensitized Solar Cells

Kazuaki Tamiya and Kozo Taguchi Science and Engineer, Ritsumeikan University, Kusatsu City, Japan Email: ro0023hr@ed.ritsumeikan.ac.jp, taguchi@se.ritsumei.ac.jp

Abstract-Carbon nanotubes (CNT) counter electrodes for dye-sensitized solar cells (DSSCs) were prepared by electrophoretic deposition (EPD). It was shown to be a convenient method to fabricate uniform coatings of CNT with desired thickness by changing voltage, electrophoresis time and inter electrode distance. Currently, CNT counter electrodes are lower conversion efficiency than that of Pt counter electrodes, and it needs to improve conversion efficiency as much as possible. We found that when we fabricated CNT counter electrodes at 500 °C, both conversion efficiency and surface area obtained the best result. In this study, we examined that when we controlled film thickness by using EPD, how it would affect the conversion efficiency. We fixed DC voltage at 15V and controlled film thickness from 5µm to 20µm. After that, we sintered it at 500 °C and measured the conversion efficiency. As experimental results, we achieved the highest efficiency at 10µm and 2.4 %.

Index Terms—Dye-Sensitized Solar Cells (DSSCs), Carbon Nanotubes (CNT), Electrophoretic Deposition (EPD), conversion efficiency, film thickness, surface area rate

I. INTRODUCTION

Currently, researches about solar power generation are studied actively. There is a silicon shortage all over the world so currently dye-sensitized solar cells (DSSCs) have attracted much attention for their practical application as an alternative to p-n junction solar cells [1]-[12]. Above all, the study of DSSCs fabricated only organic materials without using silicon is active. Also, Pt used in a counter electrodes of DSSCs is a rare metal and has become more expensive than gold. But Pt demand of the world is rapidly increasing in such automotive catalyst. Production of Pt has remained at 150 tons per year and we worry about that the balance of supply and demand is lost. The development of counter electrodes material replaced Pt has been required in order to stabilize of the beneficiaries for balance and reduce costs. CNT is high conductivity, light, large surface area and flexibility. Using CNT which is an organic material instead of Pt, it has become possible to create low cost solar cells. CNT has many problems such as a low conversion efficiency and degradation early as compared with Pt. In this work, we aimed at fabricating processes of counter electrode.



II. DSSCs

Generally, DSSCs consist of transparent electrode, TiO₂, pigment, electrolyte and counter electrode as shown in Fig. 1. Transparence conductive film is formed on the transparent electrode and porous TiO₂ is formed on that. Porous TiO₂ consists of TiO₂ particle around 15nm. Pigment (MK-II) is absorbed on the TiO₂ surface. MK-II has functional groups such as carboxyl groups, hexyl groups. TiO₂ and pigment are bonded each other through chemical bond by dehydrogenation reaction the carboxyl groups [13], [14]. MK-II has advantages such as less limitation of resources than the ruthenium complex, having high molar absorptivity by π - π transition, structures are various and improvement easily. The hexyl groups have efforts reducing aggregate formation by π - π stacking between molecules. In this way, we can improve electronic infusion efficiency from the MK-II to TiO₂. Fig. 2 shows structural formula of the MK-II. Counter electrode is formed catalyst activating oxidationreduction and DSSCs are formed oxidation-reduction property electrolyte between electrodes. As an operation principal, when the light shines the pigment from the outside, the pigment absorbed the light and electron is exited. The electron is injected into the conductor of TiO₂ in picosecond order and flow the electric circuit. The pigment oxidized receives electron from electrolyte and

Manuscript received August 11, 2012; revised October 17, 2015.

returns ground state pigment. While, the electrolyte transferred electron to the pigment and oxidized electrolyte diffused toward counter electrode, then receives electron from counter electrode and returns reduction state electrolyte. The electron flowing the circuit reaches counter electrode and oxidized counter electrode is reduced and returns original state. This is how electrons circulate and generate electricity by exposing the light.



Figure 2. MK-II structural formula.

III. ELECTROPHORETIC DEPOSITION (EPD)

When a pair of electrodes put in the solution and DC current flows, electrophoretic deposition is the phenomenon particles charged in the solution move to the opposite electrode. Fig. 3 shows view of EPD. When particles charged positively, particles move to cathode. In contrast, when particles charged negatively, particles move to anode.



Figure 3. Over view of EPD.

EPD can divide, analysis and collect the molecule charged particles. Molecular weight and shape are difference. As advantages of EPD are (1) manufacturing processes are quick and easy to control film thickness, in other words, EPD can control the film thickness by changing various parameters (applied voltage, applied time, concentration of the dispersion) (2) EPD can form on large area and not level substrate, (3) EPD uses simple device and is cheap.

IV. EXPERIMENTAL

Instead of Pt, we used CNT for DSSC. In order to use EPD, we used CNT dispersion (meijo nano carbon). At present several methods have been employed for the fabrication of CNT counter electrodes such as chemical vapor deposition [15]-[17], screen-printing [18], drop coating [19], [20], spin coating, and spray coating [21]. The solvent of CNT dispersion was Isopropyl alcohol and concentration was 1wt%. As first step of fabricating CNT counter electrode, we used ultrasonic process for CNT dispersion. Because, usually CNT was aggregation state, we could not obtain characteristic as nano structure substance when we use as is. As next step, we used EPD. The aluminum (2cm×4cm) was used as substrates (cathode), connected to the negative potential, and counter electrode was FTO (anode) with same area. Two electrodes were kept parallel at 9mm apart in the suspension. Applying a constant DC voltage of 15 V for different times carried out EPD. In this work, the CNT electrode with different deposition times at 0.5, 1, 1.5, and 2 min. After that, we sintered them at $300 \,$ °C, $350 \,$ °C, 400 ℃, 500 ℃ and 550 ℃. We measured surface area of counter electrodes by using atomic force CNT microscope (AFM). We changed sintering temperature of them because we expected that contacting suspension surface area of CNT changed if we changed sintering temperature.

As TiO2 substrate fabricating, we mixed 20 ml of ethanol (Wako junnyaku) with for 0.1g of TiO₂ and agitated for an hour with magnetic stirrer (700rpm, 25 °C). Applying a constant DC current of 0.12A for 1.5min carried out EPD. We used aluminum (2cm×2cm) as substrats (anode), connected to the positive potential, and counter electrode was FTO (cathode) with same area. After that, it was dried for 5min at room temperature and sintered at 450 °C for 1.5h.

In process of absorbing pigment, we mixed 10mg of MK-II dye (sigma-aldrich) and 108mg of toluene (Wako junyaku) at 25 °C until all dyes were dissolved. TiO₂ substrate were immersed into MK-II dye solution and kept for 3h at 25 °C. After that, the dye-treated electrodes were rinsed with pure water and dried for 5min at 80 °C.

In process of electrolyte fabricating, we mixed 1.597g of 1.2-dimethyl-3-propylimidazolium iodide (Wako junyaku), 0.134g of LiI (sigma-aldrich), 0.508g of I_2 (sigma-aldrich), 0.676g of 4-tert-butylpyridine (sigma-aldrich) and 10mg of acetonitrile.



We fabricated DSSCs by using made TiO_2 substrate, electrolyte and CNT counter electrode. We made space between TiO_2 substrate and CNT counter electrode by using mending tape and injected electrolyte. Fig. 4 shows DSSC.

The thickness of the prepared CNT electrodes was measured by using a surface profiler (Dektak). The conversion efficiency was measured by using solar simulator (Optical Associates Inc) at 1sun (AM 1.5G, 100 mW cm-2), which was calibrated with a reference Si reference solar cell.

Conversion efficiency is the highest when it is sintered at 500 °C and it is 2.50%. Based on this, we measured conversion efficiency when we used various film thickness CNT counter electrode at 500 °C.





Figure 5. AFM image of the CNT counter electrode at (A) 300 $\ensuremath{\mathbb{C}}$, (B) 350 °C, (C) 400 °C, (D) 500 °C, (E) 550 °C.

Then, when we measure surface area of CNT counter electrode, we used the CNT counter electrode fabricated by EPD applied a constant DC voltage of 15V and 1 min. After that, we changed the sintering temperature and measured surface area of CNT counter electrode. Fig. 5 shows surface images. This measurement conditions are that measurement area is $5\mu m \times 5\mu m$ and resolving is 5nm. From these results of Table I and Fig. 5, the surface rate gradually increased from 300 °C, but it decreased from 550 °C. As these results, when we fabricated CNT counter electrode at 500 °C, the highest surface rate is at 500 °C. We expected that CNT counter electrode fabricated at 500 $^{\circ}$ C is the best for DSSC.

TABLE I. SINTERING TEMPERATURE AND SURFACE ARE RATE



Figure 6. Sintering temperature and conversion efficiency.

Fig. 6 measured sintering temperature and conversion efficiency. It is said that fabricating at 500 °C can get the highest conversion efficiency when CNT counter electrode fabricated by EPD applied a constant DC voltage. Then, we fabricated CNT counter electrodes by EPD applied a constant DC voltage of 15V and changed EPD time from 0.5min to 2min and sintered 500 ℃. We measured the conversion efficiencies and we worked the difference by the film thickness. As a result of measurement, Table II and Fig. 7, the conversion efficiency gradually increased from 5 μ m and it decreased from 10 μ m. Because increased impedance of counter electrode when increased film thickness, we considered that electric current hard to flow. Due to the aforementioned reasons, surface rate, sintering temperature and film thickness is important to conversion efficiency for DSSC.

Film thickness (µm)	Conversion efficiency (%)
5.0	1.88
9.2	2.40
17	1.25
22	0.77



Figure 7. Relation of film thickness and conversion efficiency.

V. CONCLUSION

CNT counter electrode has been successfully fabricated by EPD and used for DSSC. Because CNT counter electrode consists of nanostructure substance with large surface area. When we fabricated CNT counter electrode at 500 °C, the surface area rate reached maximally 2.78, and by the controlling of film thickness of CNT counter electrode, conversion efficiency of the DSSCs reached maximally 2.4%. Film thickness, sintering temperature and surface area rate are important for conversion efficiency of DSSCs. We expect that EPD method is a promising fabrication technique for a low cost production, fabrication easily production, flexible and conductive counter electrode for DSSCs

ACKNOWLEDGEMENT

The authors wish to thank to Minemoto laboratory in Ritsumeikan university. We got to use Solar simulator (OAI, TriSOL) and Step gauge (BRUKER DektakXT) for simulating DSSC performance.

REFERENCE

 J. Cho, K. Konopka, K. Rozniatowski, E. Garcia-Lecina, M. S. P. Shaffer, and A. R. Boccaccini, "Characterisation of carbon nanotube films deposited by electrophoretic deposition," *CARBON*, vol. 47, pp. 58–67, 2009.

- [2] B. O'. Regan and M. Grätzel, "A low-cost, high-efficiency solar cell based on dye-sensitized colloidal TiO₂ films," *Nature*, pp. 353-737, 1991.
- [3] G. Smestad, C. Bignozzi, and R. Argazzi, "Testing of dye sensitized TiO₂ solar cells I: Experimental photocurrent output and conversion efficiencies," *Sol. Energy Mater. Sol. Cells*, vol. 32, pp. 259, 1994.
- [4] Z. Q. Lin, Y. K. Lai, R. G. Hu, J. Li, R. G. Du, and C. J. Lin, "A highly efficient ZnS/CdS@TiO₂ photoelectrode for photogenerated cathodic protection of metals," *Electrochim Acta*, vol. 55, pp. 8717, 2010.
- [5] H. J. Tian, L. H. Hu, W. X. Li, J. Sheng, S. Y. Xu, S. Y. Dai, and J. Mater, "Superior energy band structure and retarded charge recombination for Anatase N, B codoped nano-crystalline TiO₂ anodes in dye-sensitized solar cells," *Chem. Commun*, vol. 21 pp. 7074, 2011.
- [6] P. Sudhagar, J. H. Jung, S. Park, R. Sathyamoorthy, H. Ahn, and Y. S. Kang, "The performance of coupled (CdS: CdSe) quantum dot-sensitized TiO₂ nano fibrous solar cells," *Electrochim. Acta*, vol. 55 pp. 113, 2009.
- [7] W. Y. Fu, H. B. Yang, P. Sun, Y. Y. Zhang, L. R. Wang, W. Y. Zhao, H. Zhao, et, al. "Chemical bath deposition of Cu₂O quantum dots onto ZnO nano rod arrays for application in photovoltaic devices," *RSC Advances*, vol. 30 pp. 23401-23409, 2015.
- [8] G. Zhu, L. Pan, T. Xu, Q. Zhao, B. Lu, and Z. Sun "Microwave assisted CdSe quantum dot deposition on TiO₂ films for dyesensitized solar cells," *Nanoscale*, vol. 3, pp. 2188, 2011.
- [9] J. Z. Chen, B. Li, J. F. Zheng, J. H. Zhao, H. W. Jing, and Z. P. Zhu, "Polyaniline nano fiber/carbon film as flexible counter electrodes in platinum-free dye-sensitized solar cells," *Electrochim Acta*, vol. 56, pp. 4624, 2011.
- [10] X. Z. Liu, Y. H. Luo, H. Li, Y. Z. Fan, Z. X. Yu, Y. Lin, et al., "Ce phosphors as a scattering layer for high-efficiency dye sensitized solar cells," *Chem. Commun*, vol. 27 pp. 2847, 2007.
- [11] W. Guo, Y. H. Shen, G. Boschloo, A. Hagfeldt, and T. Ma "Influence of nitrogen dopants on N-doped TiO₂ electrodes and their applications in dye-sensitized solar cells," *Electrochimica Acta*, vol. 5, pp. 4611–4617, 2011.
- [12] W. Shao, F. Gu, L. L. Gai, C. Z. Li, *et al.*, "Forest-like TiO₂ hierarchical structures for efficient dye-sensitized solar cells," *Chem. Commun*, vol. 22, pp. 6824, 2010.
 [13] Z. S. Wang, N. Koumura, Y. Cui, M. Takahashi, H. Sekiguchi, *et*
- [13] Z. S. Wang, N. Koumura, Y. Cui, M. Takahashi, H. Sekiguchi, et al., "Organic dyes for efficient and stable dye-sensitized solar cells," *Material Matters*, vol. 4, no. 4, pp. 92, 2009.
- [14] N. Koumura, Z. S. Wang, M. Miyashita, H. Sekiguchi, Y. Cui, A. Mori, and S. Mori, "Substituted carbazole dyes for efficient molecular photovoltaics: long electron lifetime and high open circuit voltage performance," *Mater. Chem.*, vol. 19, pp. 4829-4836, 2009.
- [15] H. Choi, H. Kim, S. Hwang, W. Choi, and M. Jeon, "Graphene counter electrodes for dye-sensitized solar cells prepared by electrophoretic deposition," *Mater. Chem.*, vol. 21 pp. 7548, 2011.
- [16] S. U. Lee, W. S. Choi, *et al.*, "Fabrication and characterization of carbon-based counter electrodes prepared by electrophoretic deposition for dye-sensitized solar cells," *Energy Mater. Sol. Cells*, vol. 95 pp. 323, 2011.
- [17] K. S. Lee, W. J. Lee, N. G. Park, S. O. Kim, and J. H. Park, "Transferred vertically aligned N-doped carbon nanotube arrays: use in dye-sensitized solar cells as counter electrodes," *Chem. Commun*, vol. 47 pp. 4264, 2011.
- [18] S. H. Seo, S. Y. Kim, B. K. Koo, S. I. Cha, and D. Y. Lee, "Influence of electrolyte composition on the photovoltaic performance and stability of dye-sensitized solar cells with multiwalled carbon nanotube," *Catalysts Langmuir*, vol. 26, pp. 10341–10346, 2010.
- [19] G. Calogero, F. Bonaccorso, O. M. Maragò, P. G. Gucciardi, and G. D. Marcoa, "Single wall carbon nanotubes deposited on stainless steel sheet substrates as novel counter electrodes for ruthenium polypyridine based dye sensitized solar cells," *Dalton Trans*, vol. 39, pp. 2903, 2010.
- [20] C. S. Chou, C. Huang, R. Y. Yang, and C. P. Wang, "The effect of SWCNT with the functional group deposited on the counter electrode on the dye-sensitized solar cell," *Adv. Powder Technol*, vol. 21, pp. 542, 2010.

- [21] J. Han, H. Kim, D. Y. Kim, S. M. Jo, and S. Y. Jang, "Water-Soluble polyelectrolyte-grafted multiwalled carbon nanotube thin films for efficient counter electrode of dye-sensitized solar cells," *ACS Nano.*, vol. 4, pp. 3503, 2010.
- [22] H. Chang, T. J. Hsieh, T. L. Chen, K. D. Huang, C. S. Jwo, and S. H. Chien, "Dye-Sensitized solar cells made with TiO₂-Coated multi-wall carbon nanotubes and natural dyes," *Materals Transactions*, vol. 50, pp. 2879-2884, 2009.



Kazuaki Tamiya was born in Kyoto, Japan on January 23, 1993. He received bachelor's degree in Department of Science and Engineering from Ritsumeikan University, Shiga, Japan in May 2015 and was admitted to a postgraduate course at same University on April 2015. He also belongs to an electronics system course of Department of Science and Engineering. He is now in the first year of his degree. He is studying CNT counter electrode

for DSSC by using electrophoretic deposition in the graduate course.



Kozo Taguchi was born in Kyoto, Japan, on December 18, 1968. He received the B.E., M.E., and Dr. Eng. degrees in electrical engineering from Ritsumeikan University, Kyoto, Japan, in 1991, 1993, and 1996, respectively. In 1996, he joined Fukuyama University, Hiroshima, Japan, where he had been engaged in research and development on the optical fiber trapping system. lasers and their semiconductor ring

application for optoelectronics devices, and polymeric optical waveguides for optical interconnection. In 1996-2003, he worked as an assistant and lecturer in Fukuyama University. In 2003, he moved to Ritsumeikan University, Shiga, Japan, and currently he is a professor of department of electric and electronic engineering. From 2006 to 2007, he was a visiting professor at University of St Andrews (Scotland, United Kingdom). From 2014 to 2015, he was a visiting professor at Nanyang Technological University (Singapore). His current research interests include cells trap, microfluidic cell based devices, dye sensitized solar cell, biofuel cells. Dr. Taguchi is a member of the SPIE.